RH1013 OPERATIONAL AMPLIFIER DICE

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0	INIT	IAL RI	ELEASE																06/	/15/00
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	 REMOVED THE "M" FROM THE DEVICE TITLE, THROUGHOUT THE SPEC, TO MATCH THE DATA SHEET AND RPL. PAGE 3, PARAGRAPH 3.7.1, CHANGED THE DOSAGE RATE FROM "APPROXIMATELY 20 																			
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С	PACKAGE TYPES AT TOP OF PAGE, AND HAVE ALL FIGURES AT BOTTOM OF PAGE. • CONVERSION OF SPECIFICATION FROM WORD PERFECT TO MICROSOFT WORD. • PAGE 3, CHANGED INITIAL RATE OF RADS TO 240 RADS/SEC. 03/21										/21/05									
D			3, PARA									ADS/	SEC.							/05/08
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													-						02/	10/09
	ADDED TEMPERATURE CYCLE, CONSTANT ACCELERATION & REMOVED PIND TEST. Page 2, amended section 3.3, Special Handling of Dice, to more accurately describe our current									03	/30/12									
	Page 2, amended section 3.3, <u>Special Handling of Dice</u> , to more accurately describe our current procedures and requirements.								03/	30/12										
	Page 13, Changed RH Canned Sample Table for Qualifying Dice Sales: Subgroup 6 Sample Size									07	/02/13									
	Series changed from 45 (3) to 65 (3). First note had the Sample Size Series from "15%" to "10%". Updated Die Sales table on pg 13.								02/13											
									05/	/22/15										
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	thermal shutdown temperature Removed Source Inspection (6.4.1) 01/2																			
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M	To r	emove	source	inspe	ction a	and ch	ange	Linea	ar t	o A	nalog								01	/29/21
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FOR OFFICIAL USE ONLY

1.0 SCOPE:

1.1 This specification defines the performance and test requirements for a microcircuit processed to a space level manufacturing flow.

2.0 APPLICABLE DOCUMENTS:

2.1 <u>Government Specifications and Standards</u>: the following documents listed in the Department of Defense Index of Specifications and Standards, of the issue in effect on the date of solicitation, form a part of this specification to the extent specified herein.

SPECIFICATIONS:

MIL-PRF-38535 Integrated Circuits (Microcircuits) Manufacturing, General Specification

for

MIL-STD-883 Test Method and Procedures for Microcircuits

MIL-STD-1835 Microcircuits Case Outlines

2.2 <u>Order of Precedence</u>: In the event of a conflict between the documents referenced herein and the contents of this specification, the order of precedence shall be this specification, MIL-PRF-38535 and other referenced specifications.

3.0 REQUIREMENTS:

- 3.1 <u>General Description</u>: This specification details the requirements for the RH1013 Operational Amplifier Dice and Element Evaluation Test Samples, processed to space level manufacturing flow as specified herein.
- 3.2 Part Number: RH1013 Dice
- 3.3 Special Handling of Dice: Rad Hard dice require special handling as compared to standard IC dice. Rad Hard dice are susceptible to surface damage due to the absence of silicon nitride passivation that is present on most standard dice. Silicon nitride protects the dice surface from scratches by its hard and dense properties. The passivation on Analog Devices Rad Hard dice is silicon dioxide which is much "softer" than silicon nitride. During the visual and preparation for shipment, ESD safe Tweezers are used and only the edge of the die are touched.

ADI recommends that dice handling be performed with extreme care so as to protect the die surface from scratches. If the need arises to move the die in or out of the chip shipment tray (waffle pack), use an ESD-Safe-Plastic-tipped Bent Metal Vacuum Probe, preferably .020" OD x .010" ID (for use with tiny parts). The wand should be compatible with continuous air vacuums. The tip material should be static dissipative Delrin (or equivalent) plastic.

During die attach, care must be exercised to ensure no tweezers, or other equipment, touch the top of the dice.

3.4 The Absolute Maximum Ratings:

Note 1/ Parameter is quaranteed by design, characterization, or correlation to other tested parameters.

- 3.5 <u>Design, Construction, and Physical Dimensions</u>: Detail design, construction, physical dimensions, and electrical requirements shall be specified herein.
- 3.6 <u>Outline Dimensions and Pad Functions</u>: Dice outline dimensions, pad functions, and locations shall be specified in **Figure 1**.
- 3.7 <u>Radiation Hardness Assurance (RHA)</u>:
 - 3.7.1 The manufacturer shall perform a lot sample test as an internal process monitor for total dose radiation tolerance. The sample test is performed with MIL-STD-883 TM1019 Condition A as a guideline.
 - 3.7.2 For guaranteed radiation performance to MIL-STD-883, Method 1019, total dose irradiation, the manufacturer will provide certified RAD testing and report through an independent test laboratory when required as a customer purchase order line item.
 - 3.7.3 Total dose bias circuit is specified in **Figure 2**.
- 3.8 <u>Wafer (or Dice) Probe</u>: Dice shall be 100% probed at Ta = +25°C to the limits shown in **Table I** herein. All reject dice shall be removed from the lot. This testing is normally performed prior to dicing the wafer into chips. Final specifications after assembly are sample tested during the element evaluation.
- 3.9 <u>Wafer Lot Acceptance</u>: Wafer lot acceptance shall be in accordance with MIL-PRF-38535, Appendix A, except for the following: Top side glassivation thickness shall be a **minimum of 4KÅ**.
- 3.10 <u>Wafer Lot Acceptance Report</u>: SEM is performed per MIL-STD-883, Method 2018. Copies of SEM photographs shall be supplied with the Wafer Lot Acceptance Report as part of a Space Data Pack when specified as a customer purchase order line item.
- 3.11 <u>Traceability</u>: Wafer Diffusion Lot and Wafer traceability shall be maintained through Quality Conformance Inspection.
- 4.0 QUALITY CONFORMANCE INSPECTION: Quality Conformance Inspection shall consist of the tests and inspections specified herein.

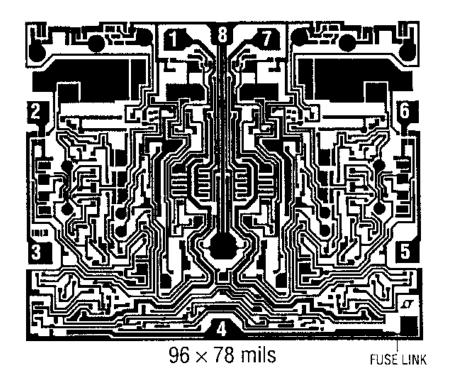
- 5.0 SAMPLE ELEMENT EVALUATION: A sample from **each wafer supplying dice** shall be assembled and subjected to element evaluation per **Table III** herein.
 - 5.1 <u>100 Percent Visual Inspection</u>: All dice supplied to this specification shall be inspected in accordance with MIL-STD-883, Method 2010, Condition A. All reject dice shall be removed from the lot.
 - 5.2 <u>Electrical Performance Characteristics for Element Evaluation</u>: The electrical performance characteristics shall be as specified in **Table I** and **Table II** herein.
 - 5.3 <u>Sample Testing</u>: Each wafer supplying dice for delivery to this specification shall be subjected to element evaluation sample testing. No dice shall be delivered until all the lot sample testing has been performed and the results found to be acceptable unless the customer supplies a written approval for shipment prior to completion of wafer qualification as specified in this specification.
 - 5.4 Part Marking of Element Evaluation Sample Includes:
 - 5.4.1 LTC Logo
 - 5.4.2 LTC Part Number
 - 5.4.3 Date Code
 - 5.4.4 Serial Number
 - 5.4.5 ESD Identifier per MIL-PRF-38535, Appendix A
 - 5.4.6 Diffusion Lot Number
 - 5.4.7 Wafer Number
 - 5.5 <u>Burn-In Requirement</u>: Burn-In circuit for TO5 package is specified in **Figure 3**.
 - 5.6 <u>Mechanical/Packaging Requirements</u>: Case Outline and Dimensions are in accordance with **Figure 4.**
 - 5.7 <u>Terminal Connections</u>: The terminal connections shall be as specified in Figure 5.
 - 5.8 <u>Lead Material and Finish:</u> The lead material and finish shall be Kovar with hot solder dip (Finish letter A) in accordance with MIL-PRF-38535.
- 6.0 VERIFICATION (QUALITY ASSURANCE PROVISIONS)
 - 6.1 <u>Quality Assurance Provisions</u>: Quality Assurance provisions shall be in accordance with MIL-PRF-38535. <u>Analog Devices</u> is a QML certified company and all Rad Hard candidates are assembled on qualified Class S manufacturing lines.
 - 6.2 <u>Sampling and Inspection</u>: Sampling and Inspection shall be in accordance with **Table III** herein.
 - 6.3 <u>Screening</u>: Screening requirements shall be in accordance with **Table III** herein.

- 6.4 <u>Deliverable Data</u>: Deliverable data that will ship with devices when a Space Data Pack is ordered:
 - 6.4.1 Lot Serial Number Sheets identifying all Canned Sample devices accepted through final inspection by serial number.
 - 6.4.2 100% attributes (completed element evaluation traveler).
 - 6.4.3 Element Evaluation variables data, including Burn-In and Op Life
 - 6.4.4 SEM photographs (3.10 herein)
 - 6.4.5 Wafer Lot Acceptance Report (3.9 herein)
 - 6.4.6 A copy of outside test laboratory radiation report if ordered
 - 6.4.7 Certificate of Conformance certifying that the devices meet all the requirements of this specification and have successfully completed the mandatory tests and inspections herein.

Note: Items 6.4.1 and 6.4.7 will be delivered as a minimum, with each shipment.

7.0 Packaging Requirements: Packaging shall be in accordance with Appendix A of MIL-PRF-38535. All dice shall be packaged in multicavity containers composed of conductive, anti-static, or static dissipative material with an external conductive field shielding barrier.

DICE OUTLINE DIMENSIONS AND PAD FUNCTIONS



PAD FUNCTION

- 1. OUTPUT A
- 2. INA
- 3. +INA
- 4. V⁻
- 5. +INB
- 6. -!NB
- 7. OUTPUT B
- 8. V+

FIGURE 1

TOTAL DOSE BIAS CIRCUIT

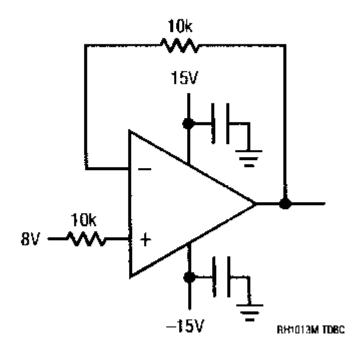


FIGURE 2

BURN-IN CIRCUIT

									OVEN OP	ION	s		
	BOA	RD STYLE:	LTC YES			LEG/	ACY OVEN	YES	5		МСС	OVEN	YES
		AVI-T	ECH NO			ОРТІМ	UM OVEN	YES	5	0	OUTSIDE	OVEN	YES
RID	ER CA	RD ASSEM	BLY:	N/A									
		PRO	OBE:	04-06-925	2								
											MIN	1°C	MAX °C
					QUANTI	TY MAXS	KTS		MBIENT TE	MD	125	:°C	133°C
		H	ARDWARE#	REV.	BOARD								
		nn. c	4 0C 002E						NCTION TE		137		141°C
			4-06-0035	A_	1	80			MBIENT TE		150		158°C
	OGE CA		N/A					10	NCTION TE		162	2*C	166°C
R	OW CA	ARD:	N/A						THERN SHUTDO			N/	Δ
									3110100	rviv.		19//	<u> </u>
DOWE	D CEO	UENCE					EVACE				** 40774 0	0.100	
FOWE	IN SEQ	COENCE			FUSE	STARTUP	STEADY S	TATE	PER ROW		MPTY B R EDGE		DICATED
ON	OFF	SUPPLY	MINV	V XAM	AMPS	CURRENT	CURRE		CARD		CARD		D PER SKT
		V1	+20.0V	+22.0V	2Amp	2mA/SKT	2mA/S		N/A		N/A		KT + 50mA
			-20.0V	-22.0V	2Amp	1.4mA/SKT	1.4mA/	SKT	N/A		N/A	0mA/	SKT + 50mA
	—	<u>V3</u>											
	—	V5											
	_												
_	TES	T POINTS					SPECIA	LNOT	ES;				
T,P,#	PI	N NAME	VALUE	D\A	R/MON O	DTIONS	- Do r	not cor	nnect V4 PV	VR.			
1		OUTA	GND	YES		/1/V4							- 1
2		OUTB	GND	1,20		/2/GND							
cloc	KC UN	VS DC			IN V	BANCE		CDEO.			ever -		romons.
CLUC	NO CN	V3 DC		101	IN V	MAX V		FREQ	D	UIY	CYCLE	V	ECTOR?
													
				-						_			

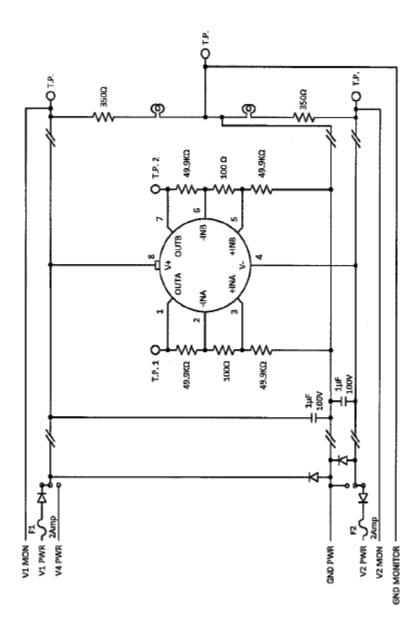
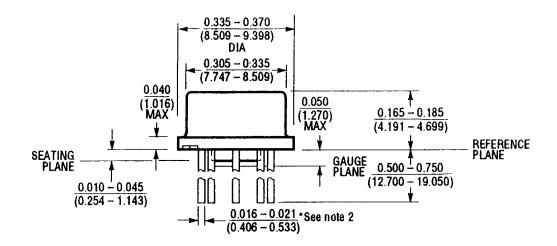
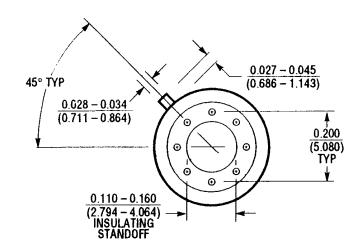


FIGURE 3

TO5, 8 LEADS, CASE OUTLINE





NOTE: 1. LEAD DIAMETER IS UNCONTROLLED BETWEEN THE REFERENCE PLANE AND SEATING PLANE.

2. FOR SOLDER DIP LEAD FINISH, LEAD DIAMETER IS

 $\frac{0.016 - 0.024}{(0.406 - 0.610)}$

FIGURE 4

$$\theta$$
ja = +150°C/W
 θ jc = +40°C/W

TERMINAL CONNECTIONS

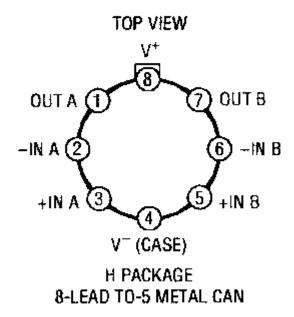


FIGURE 5

TABLE I DICE ELECTRICAL CHARACTERISTICS – Element Evaluation (Notes 1, 2)

 $V_S=\pm 15 V,\ V_{CM}=0 V,\ T_A=25^{\circ} C$ unless otherwise noted.

SYMBOL	PARAMETER	CONDITIONS	MIN	MAX	UNITS
Vos	Input Offset Voltage			300	μV
		(Note 2)		450	μV
los	Input Offset Current			10	nA
		(Note 2)		10	nA
I _B	Input Bias Current			30	nA
		(Note 2)		30	nA
A _{VOL}	Large-Signal Voltage Gain	$V_0 = \pm 10V$, $R_L \ge 2k$ $V_0 = \pm 10V$, $R_L \ge 600\Omega$	1.2 0.5		V/μV V/μV
	Input Voltage Range	(Note 1)	13.5 -15.0		V
		(Notes 1, 2)	3.5 0		V
CMRR	Common Mode Rejection Ratio	V _{CM} = 13.5V, -15V	97		dB
PSRR	Power Supply Rejection Ratio	V _S = ±2V to ±18V	100		dB
	Channel Separation	$V_0 = \pm 10V, R_L = 2k$	120		dB
V _{OUT}	Output Saturation Swing	$R_L \ge 2k$ Output Low, No Load, (Note 2) Output Low, 600Ω to GND, (Note 2) Output Low, $I_{SINK} = 1mA$, (Note 2) Output High, No Load, (Note 2) Output High, 600Ω to GND, (Note 2)	±12.5 4.0 3.4	25 10 350	V mV mV V V
SR	Slew Rate		0.2		V/µs
ls .	Supply Curent	Per Amplifier		0.55	mA
		(Note 2)		0.50	mA

Note 1: Guaranteed by design, characterization or correlation to other tested parameters.

Note 2: Specification applies for V_S+ = 5V, V_S- = 0V, V_{CM} = 0V, V_{OUT} = 1.4V.

TABLE II ELECTRICAL CHARACTERISTICS – Post-Irradiation (Notes 1, 2)

 $V_S = \pm 15 V$, $V_{CM} = 0 V$, $T_A = 25 ^{\circ} C$, unless otherwise noted.

SYMBOL	PARAMETER	CONDITIONS	NOTES	10KRA Min	D(Si) Max	20KR/ Min	D(Si) MAX	50KRA Min	D(Si) Max	100KR/ Min	AD(Si) Max	200KR		UNITS
Vos	Input Ofset Voltage				450		450		600		750		900	μV
			2		600		600		750	***	900			μV
los	Input Offset Current				10		10		15		20		25	nA
			2		10		10		15		20			nA
I _B	Input Bias Current				60		75		100		175		250	nA
			2		80		100		125		200			nA
	Input Voltage Range		1	13.5		13.5		13.5		13.5	·	13.5		V
			1	-15.0		-15.0		-15.0		-15.0		-15.0		٧
			2	3.5		3.5		3.5		3.5				V
			2	0		0		0		0				٧
CMRR	Common-Mode Rejection Ratio	V _{CM} = 13V, -15V		97		97		94		90		86		dB
PSRR	Power Supply Rejection Ratio	V _S = ±5V to ±18V		100		98		94		86		80	·	dB
A _{VOL}	Large-Signal Voltage Gain	R _L 10k, V ₀ = ±10V		500		200		100		50		25		V/mV
Vout	Maximum Dutput Voltage	R _L 10k		±12.5		±12.5		±12.5		±12.5		±12.5		V
	Swing	Output Low, No Load	2		25		30		40		50			mV
		Output Low, 600 to GND	2		10		10		10		10			m۷
		Output Low, I _{SINK} = 1mA	2		0.6		0.8		1.0		1.6			٧
		Output High, No Load	2	4.0		4.0		4.0		4.0				V
		Output High, 600 to GND	2	3.4		3.2		3.0		2.8				V
SR	Slew Rate	R _L 10k		0.13		0.12		0.11		0.07		0.01		V/µs
l _S	Supply Current	Per Amplifier			0.55		0.55		0.55		0.55		0.55	mA
			2		0.50		0.50		0.50		0.50			mA

Note 1: Guaranteed by design, characterization, or correlation to other tested parameters..

Note 2: Specification applies for V_S^+ = 5V, V_S^- = 0V, V_{CM} = 0V, V_{OUT} = 1.4V.

SPEC NO. 05-08-5112 REV. M RH1013 OPERATIONAL AMPLIFIER DICE TABLE III RH ELEMENT EVALUATION TABLE QUALIFICATION OF DICE SALE



RH CANNED SAMPLE TABLE FOR QUALIFYING DICE SALES

		CLASS	_	KIT CANNED SAMIFLE TABLE FOR QUALIFTING DICE SALES	_ }	ALIFYING DICE SALES	MIL-STD-883
SUBGROUP	ζS	<	H/B	OPERATION	METHOD	CONDITION	(ACCEPT NUMBER)
1	×	×	"	SEM	2018	N/A	REF. METHOD 2018 FOR S/S
2	×	×	×	ELEMENT ELECTRICAL (WAFER SORT @ 25°C)			100%
3	×	×	×	ELEMENT VISUAL (2nd OP)	2010	А	100%
4	×	×	×	INTERNAL VISUAL (3rd OP)	2010	Α	ASSEMBLED PARTS ONLY
	×	×	_	DIE SHEAR MONITOR	2019		
	×	X	_	BOND PULL MONITOR	2011		
5	×	×	(0	STABILIZATION BAKE	1008	О	ASSEMBLED PARTS ONLY
	×	×	_	TEMPERATURE CYCLE	1010	С	
	×	×		CONSTANT ACCELERATION	2001	E	
	×	X	_	FINE LEAK	1014	А	
	X	X		GROSS LEAK	1014	С	
6	×	×		FIRST ROOM ELECTRICAL - READ & RECORD			45(0)
				(REPLACE ANY ASSEMBLY-RELATED REJECTS)			
	X	X	_	PRE BURN-IN ELECT. READ & RECORD @ +125°C or +150°C, -55°C			
	×	×		BURN-IN: +125°C/240 hrs. or +150°C/120 hrs.	1015	+ 125°c MINIMUM 240 HOURS	
	×	×	_	POST BURN-IN ELECT. READ & RECORD @ 25°C			
	×	×		POST BURN-IN ELECT. READ & RECORD @ +125°C or +150°C, -55°C			
		X	_	TOTAL IRRADIATION DOSE	1019	А	
	×	×	_	PRE OP-LIFE ELECTRICAL @ 25°C READ & RECORD			
	×	×		OPERATING LIFE: +125°C/1000 hrs. or +150°C/500 hrs.	1005	+ 125% MINIMUM 1000 HOURS	
	X	X		POST OP-LIFE ELECT. (R & R @ 25°C, +125°C OR +150°C, -55°C			
7	X	×	×	WIRE BOND EVALUATION	2011		15(0) OR 25(1) - # of wires
NOTE:	LTC	s no	t qu	LTC is not qualified to process to MIL-PRF-38534. This is an LTC imposed element evaluation that follows	ment evaluatio	n that follows	
	MI-	STD-	883	MIL-STD-883 test methods and conditions. Please note the quantity and accept number from Sample Size Series of	ept number fro	m Sample Size Se	ries of
	5%,	ассе	pt o	5%, accept on 0, and note that the actual sample and accept number does not begin until Subgroup 6 OP-LIFE	not begin until	Subgroup 6 OP-LI	ĘĘ.
NOTE:	Test	s wit	hin S	Tests within Subgroup 5 may be performed in any sequence.			
NOTE:	LTC'	s rad	iatio	LTC's radiation tolerance (RH) die has a topside glassivation thickness of 4KA minimum.	minimum.		
NOTE:	Sam	ple s	izes	Sample sizes on the travelers may be larger than that indicated in the above table; however, the larger sample size is	table; however	r, the larger samp	le size is
	relat	ed re	eject	related rejects in Subgroup 6, and for Wire Bond Evaluation, Surgroup 7. The larger sample size is at all times	ent or operator larger sample	size is at all times	sembly
	kept	segr	egat	kept segregated and, if used for qualification, has all the required processing imposed.	imposed.		